Chemical vapour deposition of rhenium disulfide and rhenium-doped molybdenum disulfide thin films using single-source precursors

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Polycrystalline thin films of rhenium disulfide (ReS₂) and the alloys Moₓ₋ₓReₓS₂ (0 ≤ x ≤ 0.06) have been deposited by aerosol-assisted chemical vapour deposition (AA-CVD) using [Re(S₂CNEt₂)₄] (1) and [Mo(S₂CNEt₂)₄] (2) in different molar ratios at 475 °C. The deposited films were characterised by p-XRD, SEM, and ICP-OE, Raman, and EDX spectroscopies. The p-XRD patterns of the films deposited from (1) correspond to ReS₂ (x = 1) and those deposited from (2) matched to MoS₂ (x = 0). Re-doping of up to 6% was achieved in MoS₂ thin films by using different concentrations of precursor (1), the morphology of the doped films changed from lamellar for pure MoS₂ to clusters at 6 mol% alloying with rhenium. The films are promising candidates as models for the incorporation of technetium into transition metal dichalcogenides as a means of immobilisation in nuclear waste processing. Exfoliation of these films is also a potential route towards modification of the optoelectronic properties of 2D molybdenite.

Introduction

Two-dimensional transition metal dichalcogenides (TMDCs) which have the general formula MX₂2, including molybdenum disulfide (MoS₂), tungsten disulfide (WS₂), and tungsten diselenide (WSe₂) have attracted interest because of their optoelectronic properties in monolayer form1–3 with useful carrier mobilities and mechanical flexibility.4–9 MoS₂, in particular, has attracted considerable attention because of its potential applications in hydrogen storage, solid lubricants, capacitors, and electrochemical devices.10–14 MoS₂ can also be used as a catalyst (e.g. in hydrogen evolution reactions) due to its high-energy crystal edges.15 The structure of bulk MoS₂ is akin to that of graphite in terms of a repeating layer structure,16 held together by non-covalent interactions. 2H-MoS₂ bulk shows a change from an indirect bandgap to a direct bandgap as the 1H-MoS₂ monolayer form is approached,15 as per MoSe₂, WS₂, and WSe₂.17,18 MoS₂ thin films have been synthesised by aerosol assisted chemical vapour deposition (AA-CVD) using metal dithiocarbamate-based precursors.19 Thin films of MoS₂ doped with Re have been previously synthesised by using spray pyrolysis.20 We and others have recently developed a general approach to doping MoS₂ with transition metal cations such as chromium based on AA-CVD.21,22 Rhenium disulfide (ReS₂) has a direct bandgap which remains as such in the monolayer form unlike most other TMDCs. Few, if any, changes are observed in the Raman spectrum of monolayer ReS₂ compared to bulk and few-layer variants.23 Transition metal doped ReS₂ has been reported.24 Single crystals of Mo-doped ReS₂ have been synthesised by chemical vapour transport method with bromine as a transport agent.25 The growth of ReS₂ monolayers has been achieved using CVD at 450 °C, the as-deposited ReS₂ is an n-type semiconductor.26 Colloidal ReS₂ nanoparticles have also been prepared.27 Two-dimensional nanosheets of ReS₂ have been synthesised by lithium intercalation, and have unique photocatalytic properties which can potentially be superior to other two-dimensional materials.28 Large area deposition of ReS₂ sheets with good crystallinity has been achieved using simple CVD, from ReO₃ treated with elemental sulfur vapour at 500 °C.29 Rhenium-doped MoS₂ can potentially be used as a model for immobilization of radioactive technetium-99 (⁹⁹Tc).30 Technetium-99 is very mobile in water hence there is concern about its release into the environment. In 2008 the production of ⁹⁹Tc was close to 290 metric tonnes worldwide.31 Technetium-99 is produced from uranium fission, and is present in nature at a very low level.32 ⁹⁹Tc has a long half-life (ca. 2 × 10⁵ years), and it forms about 6% of the fission product from uranium.33,34 The relatively short-lived isotope ⁹⁹mTc is a widely used radionuclide in nuclear medicine.35 The ionic radii of Te⁵⁺ and Mo⁴⁺ are 0.65, 0.63 and 0.65 Å respectively, whilst the Shannon–Prewitt crystal radii of [Te⁵⁺ = 0.65 Å, Mo⁴⁺ = 0.63 Å].

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Tc(\text{IV}), Re(\text{IV}) and Mo(\text{IV}) are also similar, 0.79, 0.77 and 0.79 Å respectively. The Gibbs free energy change associated with the formation of the M(\text{IV}) oxidation state from elemental rhenium and technetium are $\Delta G = 1.3 F$ and 1.1F kJ mol$^{-1}$ respectively, where $F$ is the Faraday constant. Hence from these data it may be surmised that isovalent substitution of Re into MoS$_2$ may be performed without significant induced strain in the lattice and minimal free energy penalty from disruption of the host lattice and that rhenium(\text{IV}) is a good model for technetium(\text{IV}). Entrainment of Re into host structures such as iron phosphate glasses is also known.

In this paper we report the deposition of Mo$_{1-x}$Re$_x$S$_2$ (0 $\leq$ x $\leq$ 0.06) alloyed thin films using AA-CVD from Mo and Re single source precursors. Molybdenite exists usually as the 2H stacked (ABA) polytype (P6$_{3}$mmc). Rhenium disulfide has a different layered structure that is classified in the P1 space group, of much lower symmetry than most transition metal dichalcogenides which seems to be driven by the participation of each d$^{5}$-Re ion bonding to three others in the same layer which results in the formation of Re$_3$ parallelograms, with vertices linked in a linear fashion throughout the sheet. The Re-based parallelograms dictate the relative displacements of the sulfur atoms in the hexagonal close packed arrays, and due to this, the sulfur atoms in the layer are rippled on the sheet surface, in contrast to MoS$_2$, where the sulfur layers appear smooth. At low levels of rhenium incorporation we find that the parent molybdenite structure holds due to the aforementioned similarities in crystal radii and the thermodynamic similarities in their +4 oxidation state. Significantly, this makes Re-doped MoS$_2$ a potentially useful model system for understanding the thermodynamic stability of $^{99}$Tc in a host molybdenum disulfide lattice which will be of particular interest in nuclear chemistry for storage capability-building using inert materials that do not leak radioactive material. This is the first example of single source precursors being used to produce such materials.

**Experimental section**

All reactions were carried out under dry nitrogen atmosphere using standard Schlenk techniques. Solvents were purchased from Sigma-Aldrich or Fisher and used without further purification. Reagents were purchased from Sigma-Aldrich.

**Instrumentation**

Elemental analysis was performed by the University of Manchester micro-analytical laboratory. A Seiko SSC/S200 model was used for TGA measurements with a heating rate of 10 °C min$^{-1}$ under nitrogen. Scanning electron microscopy (SEM) was performed in secondary electron mode with a Zeiss Ultra55 microscope with an accelerating voltage of 10 kV. Energy-dispersive X-ray (EDX) spectroscopy was performed on the same system at an accelerating voltage of 30 kV using an Oxford Instruments INCA pentaFETx3 detector.

Transmission electron microscopy (TEM) was performed on a FEI Tecnai G2 operating at 200 kV. Nuclear magnetic resonance (NMR) spectra were recorded using a 400 MHz Bruker spectrometer. A Bruker D8 AXE diffractometer was used to record p-XRD patterns, equipped with a Cu-K$_\alpha$ source (1.5406 Å). Thin films were scanned between 10 and 80° with step size 0.02° and a dwell time of 3 s.

**Synthesis of rhenium nonachloride (Re$_2$Cl$_9$)**

The apparatus was dried by heat gun in a stream of dry nitrogen, and then was moved with the stopcock closed into a glove bag. Rhenium pentachloride (ReCl$_5$, 2.35 g) was added into the tube and moved from the glove bag and clamped, with a moderate stream of N$_2$. The tube was heated in a slow Bunsen burner flame, after that the ReCl$_5$ started to melt and the vapour was under reflux. Brown fumes were observed to be liberated. Heating was stopped during the reaction at regular intervals to harvest the crystals which were formed on the wall of tube. This process was repeated until no more brown fumes were liberated and only solid remained. The apparatus was allowed to cool, and the tube sealed off and moved to a nitrogen filled glove bag to transfer the product, a black-red solid, into an anmpoule. Yield: 72%. Anal. calc. for Re$_2$Cl$_9$ (%): Re, 63.65; Cl, 36.65. Found (%): Re, 61.63; Cl, 36.57.

**Synthesis of (Re$_2$Cl$_9$(THF)$_3$)**

Re$_2$Cl$_9$(THF)$_3$ was prepared as previously reported. Re$_2$Cl$_6$ (2.3 g, 2.6 mmol) was placed into a thimble in the Soxhlet, then Re$_2$Cl$_9$ was extracted from a Soxhlet thimble by refluxing with THF (40 mL) under nitrogen over 48 h or more until the solvent passing through the thimble became colorless. The THF solvent was evaporated and then dark purple solid was collected and washed with diethyl ether (2 x 20 mL). Traces of solvent were removed in vacuo to furnish the title product. Yield: 58%. IR ($\nu$$_{max}$/cm$^{-1}$): 2956 (w) 1481 (w), 1442 (w), 1336 (w), 1042 (w), 1014 (m), 917 (w), 839 (s), 686 (w).

**Synthesis of rhenium iso-propylthiolate Re$_2$(µ-SPr)$_3$(SPr)$_6$**

This compound was prepared using the method of Cohen and co-workers. Briefly, Re$_2$Cl$_6$(THF)$_3$ (1.7 g, 1.5 mmol) was dissolved in of THF (140 mL). Sodium isopropylthiolate (1.7 g, 17.8 mmol) was added to the red solution of Re$_2$Cl$_6$(THF)$_3$. This mixture was refluxed for 48 h after which the THF was removed under reduced pressure. The resulting solid was then extracted with hexane (5 x 20 mL); the combined organic phase was filtered through Celite, the solvent was removed by reduced pressure then dried by vacuum oven overnight. Yield: 55%. Anal. calc. for Re$_2$S$_3$C$_2$H$_{43}$ (%): C, 26.28; H, 5.14; found (%): C, 25.82; H, 5.77. $^1$H NMR (CDCl$_3$, 400 MHz) $\delta$/ppm: 1.18 (d, $J$ = 6.81 Hz, 3H, SCH$_{Me_3}$), 1.21 (d, $J$ = 6.81 Hz, 3H, SCH$_{Me_2}$) 1.23 (d, $J$ = 6.56 Hz, 3H, SCH$_{Me_2}$) 1.27 (d, $J$ = 6.81 Hz, 3H, SCH$_{Me_2}$), 1.37 (d, $J$ = 6.81 Hz, 4H, SCH$_{Me_2}$), 1.42 (d, $J$ = 6.81 Hz, 4H, SCH$_{Me_2}$), 1.58 (d, $J$ = 6.81 Hz, 4H, SCH$_{Me_2}$), 1.70 (d, $J$ = 4.29 Hz, 3H, SCH$_{Me_2}$), 1.71 (d, $J$ = 4.29 Hz, 3H, SCH$_{Me_2}$), 2.84–2.96 (septet, 1H, SCH$_{Me_2}$), 3.40–3.53 (septet, 1H, SCH$_{Me_2}$), 3.55–3.67 (septet, 1H, SCH$_{Me_2}$), 3.99–4.12 (septet, 1H, SCH$_{Me_2}$), 4.19–4.32 (septet, 1H), 4.34–4.45 (septet, 1H, SCH$_{Me_2}$), 5.12 (s, 1H, CDCl$_3$) $\delta$/ppm: 22.61 (s, 5C), 25.40 (s, 2C), 25.71 (s, 2C), 26.46 (s, 2C), 27.11 (s, 2C) 27.78 (s, 2C), 28.07 (s, 2C), 28.21 (d, $J$ = 2.21 Hz, 5C), 28.50 (s, 2C), 30.95 (s, 2C), 32.23
(s, 1C), 37.32 (s, 1C), 37.78 (s, 1C), 41.46 (s, 2C), 44.02 (d, J = 7.37 Hz, 3C), 44.05–44.28 (m, 2C), 46.89 (s, 1C).

Synthesis of tetakis(diethylenedithiocarbamato) molybdate(IV) ([Mo(S2CNEt2)4]2 (2)
A mixture of Mo(CO)6 (10 g, 37.8 mmol) and bis(diethylthio- carbamoyl)disulfide (22.4 g, 75.6 mmol) was dissolved in degassed acetone (400 mL) and heated under reflux at a temperature range of 55–60 °C for 2 h. The mixture was cooled to room temperature, which prompted violet crystals to appear which were filtered and washed with pentane and dried in vacuo, to yield the title product as dark microcrystals. Yield: 63%. Anal. calc. for C20H40MoN4S8 (%) C, 34.88; H, 5.86; N, 8.14; S 37.16. Found (%) C, 35.04; H, 6.05; N, 8.08; S 37.33. mp 126–128 °C. MS (ES+) m/z: 690.1 [M + H]+.

Aerosol-assisted chemical vapour deposition (AA-CVD)
AA-CVD was used to deposit the rhenium or molybdenum sulfide thin films by employing [Re(μ-SPr)3(SPr)3]1 (1) or [Mo(S2CNEt2)4]2 (2), at concentrations of 0.1 mmol in 40 mL of THF at 475 °C. In addition, 0.1 mmol of total precursors (mol [Mo(S2CNEt2)4]) and mol [Re(μ-SPr)3(SPr)3]) were dissolved in (40 mL) THF to give solutions with differing composition (10, 20, 30, and 50 mol%) to synthesis Re-doped MoS2. Argon was used as an inert gas carrier with flow rate 180 sccm in to the furnace where precursors decomposed and deposit on the glass substrates (1 × 2 cm), which has been ultrasonically cleaned in isopropanol prior to use. The flow rate of argon was controlled using Platon flow gauge. Depositions typically lasted for ca. ~3 h.

Results and discussion
Synthesis and characterisation of the rhenium and molybdenum precursors
Re[μ-SPr]3(SPr)3 (1) and Mo(S2CNEt2)4 (2) were synthesised by literature procedures. All characterisation data matched with that previously reported. Complex (1) was a dark red powder, whilst complex (2) appeared as dark purple crystals. Both precursors were freely soluble in THF. Thermogravimetric analysis (TGA) of complexes (1) and (2) was used to determine the thermal decomposition range for both complexes (Fig. 1). Precursor (1) decomposed in four steps in the temperature ranges of: 40–90 °C, 140–210 °C, and 215–360 °C, followed by a slower decomposition process in the temperature range 810–1000 °C and complete decomposition occurred after 10 min. hold at 1000 °C. The remaining mass of residue (62%) suggests the formation of a rhenium sulfide (calc. 61%) (Fig. 1). Precursor (2), had a TGA profile consistent with that previously reported, showing four decomposition steps in the range 0–600 °C with a final residue (29%) close to that of MoS2 (calc. 24%).

Deposition and characterization of ReS2 thin films
Deposition of ReS2 films was performed using AA-CVD. The reactor temperature for deposition of ReS2, MoS2, and Re-doped MoS2 was chosen based on thermogravimetric analysis results (TGA, vide supra). Varying molar ratios of precursor (1) and (2) were used in a THF aerosol to achieve doped thin films which were deposited at 475 °C. The films were studied by inductively coupled plasma optical emission spectroscopy (ICP-OES), powder X-ray diffraction (p-XRD), scanning electron microscopy (SEM) and Raman and energy dispersive X-ray (EDX) spectroscopies. The p-XRD pattern of rhenium disulfide thin films deposited at 475 °C (Fig. 2) revealed two major reflections at 2θ = 14.37°, which is assigned to the (001) plane of 1T-ReS2, and at 2θ = 27.89° corresponding to the (111) plane. Thus the ReS2 produced by AACVD has an apparent preferred orientation in the (001) plane.

Raman spectroscopy of the films revealed vibrational modes that can be linked to ReS2 films. Eg modes which we ascribe to in-plane vibrations of the Re atoms in ReS2, and Ag modes corresponding to the out-of-plane vibrations of Re atoms (Fig. 3). The morphological features of thin films of rhenium sulfide were investigated by scanning electron microscopy (SEM), which revealed particles with teardrop morphology (Fig. 4a and b). Bright field transmission electron microscopy (TEM) reveals that this material is flake-like in appearance at the nanoscale (Fig. 4c–g).
which is consistent with the layered structure of ReS\(_2\). Selected area electron diffraction (SAED) patterns taken from these flakes show that they are highly crystalline (Fig. 4h).

Elemental analysis of the rhenium sulfide thin films by energy dispersive X-ray (EDX) spectroscopy. Thin films of Re\(_2\)S\(_2\) grown from Re(\(\mu\)-SiPr)\(_3\)(SiPr)\(_6\) at 475 °C analysed as follows: Re 30%, S 70% giving a composition of ReS\(_{2.3}\). Molybdenum sulfide was also grown under the same conditions; SEM and EDX and Raman spectroscopies were consistent with that previously reported for this material (ESI†).

Deposition and characterization of Mo-doped ReS\(_2\) thin films

Rhenium-alloyed thin films of molybdenum disulfide (Mo\(_1-x\)Re\(_x\)S\(_2\) where 0 ≤ \(x\) ≤ 0.06) were synthesised by AA-CVD at 475 °C. EDX spectroscopy and ICP-OES confirmed that the rhenium dopant was successfully entrained into MoS\(_2\) thin films (Fig. 5). In all cases, the incorporation of Re into MoS\(_2\) is inefficient and the amount of Re found by EDX and ICP-OES in the films is only ca. 10% of that available in the aerosol feed.

The p-XRD patterns of Mo\(_1-x\)Re\(_x\)S\(_2\) (0 ≤ \(x\) ≤ 0.06) for the ratios 1.79 and 1.80 mol% show four reflections at 2\(\theta\) = 14.3, 33.2, 39.5, and 58.7° which can be assigned to the (002), (100), (103), and (110) reflections respectively. There was no significant change with the incorporation of 1.79 and 1.80 mol% of Re on the pXRD patterns. However, on increasing the level of Re to more than 1.80 mol%, a change in the appearance of the diffraction patterns was observed; the (002) reflection became weak and broadened (Fig. 6). These changes in the powder pattern can be attributed to increasing Re mol%, which affects the stacking layers of the S–Mo–S layers in the basal plane,\(^{47}\) which has previously been observed for Cr-doped MoS\(_2\).\(^{21}\) Bright field TEM of the doped thin films (ESI†) reveal that increasing the level of Re in the films does indeed cause a shift to material with a more amorphous appearance. This could potentially be caused by the formation of intra-layer Re–Re bonds that locally disrupt the structure by S displacement (vide supra).\(^{47}\) The \(d\)-spacing for the (002) plane of the MoS\(_2\) film was 6.23 Å which is larger than that reported by Schoenfeld et al.\(^{40}\) Indeed, in our and other reports of MoS\(_2\) synthesised by AACVD from dithiocarbamato molybdenum(\(\nu\)) precursors the observed spacings of 6.25 and 6.20 Å\(^{19,21}\) suggest that MoS\(_2\) produced by AA-CVD is lattice expanded in the [002] direction as compared to bulk material. The rhenium doped MoS\(_2\) displays a monotonic increase in the \(d\)-spacing that is linear with doping, suggesting that doping of Re affords a linear lattice expansion in the [002] direction of the crystal. If the literature value of \(d\)(002) for bulk molybdenite is used,\(^{46}\) the trend becomes linear. We tentatively suggest that the effect of doping is pseudo-Vegardian.
Raman spectroscopy was used to study Mo$_{1-x}$Re$_x$S$_2$ (0 ≤ x ≤ 0.06) films. The MoS$_2$ film had two main bands observed at 407.6 cm$^{-1}$ and 380.6 cm$^{-1}$ corresponding to the A$_{1g}$ and E$_{2g}$ optical phonon modes (ESI†). The Raman spectra for the Re-doped MoS$_2$ films are shown in Fig. 7a. Significant changes in Raman spectra occurred at 3.6 mol% Re with the appearance of a band which could correspond to the A$_{1g}$ mode for ReS$_2$. Dependence of the Raman shift of the E$_{2g}$ and A$_{1g}$ optical modes of Mo$_{1-x}$Re$_x$S$_2$ on the amount of Re-dopant is shown in Fig. 7b. The difference in the magnitude of the shifts observed for both bands gives insight into the manner of doping. The A$_{1g}$ mode, which consists of the vibrational displacement of sulfur atoms only is only slightly shifted from ca. 407 cm$^{-1}$ to ca. 406 cm$^{-1}$. On the other hand, the E$_{2g}$ mode, which involves the vibration of metal and sulfur atoms in a layer is significantly shifted from ca. 382 cm$^{-1}$ to ca. 376 cm$^{-1}$. This is consistent with the substitutional doping of the heavier Re atoms into the Mo layer.

The surface morphology of the Mo$_{1-x}$Re$_x$S$_2$ (0 ≤ x ≤ 0.06) films deposited by AA-CVD at 475 °C were investigated by SEM. Different morphologies were observed on changing the amount of rhenium; MoS$_2$ had a lamellar morphology, but Re-doped MoS$_2$ 1.79% gave clusters. Increasing the Re to 3.60% gave feather-like crystals which were also observed for material with 6.25% Re (Fig. 8). Representative elemental mapping of the Re-doped MoS$_2$ thin film at 1.80% revealed that rhenium is evenly distributed in the film (Fig. 8). This was found in all alloyed films, suggesting that the isovalent substitution of Re(IV) for Mo(IV) was homogeneous under the conditions employed in this study.

**Conclusions**

Thin films of Mo$_{1-x}$Re$_x$S$_2$ (0 ≤ x ≤ 0.06) were deposited by AA-CVD from the single-source precursors Re(μ-SiPr)$_3$(SiPr)$_6$ (1) and Mo(S$_2$CNEt$_2$)$_4$ (2). The Re-doped MoS$_2$ thin films were deposited by using different molar ratios of (1) and (2). The morphology of thin films as investigated by SEM changes as the doping of MoS$_2$ with rhenium is increased.
the host molybdenum disulfide crystal due to crystal radii and thermo-
dynamic similarities between Re(IV) and Tc(IV). The materials could
also be exfoliated either by liquid or mechanical means to make
novel 2D materials; we are currently investigating this possibility.

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Fig. 8 Secondary electron SEM images (10 kV) of Mo1−xRe2S2 (0 ≤ x ≤ 0.06)
thin films deposited at 475 °C by AA-CVD. (a) 0 mol% Re, (b) 1.79 mol% Re,
(c) 1.80 mol% Re, (d) 3.60 mol% Re, (e) 6.25 mol% Re, and (f) Re2S2; thin films
were synthesized by using AA-CVD at 475 °C. EDX spectrum maps (30 kV) of
(g) Mo Lα and (h) Re Kα, emission in 1.8 mol% Re-doped MoS2 films. All scale
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